

#### **Arsenic Recovery from Irradiated Germanium Targets**

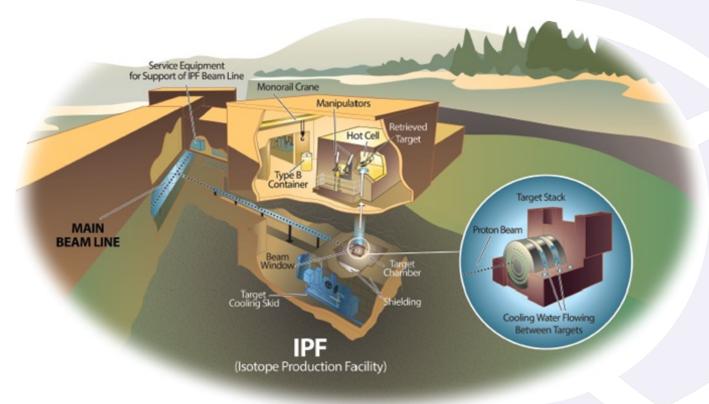
Guy R. H. Dutech, Veronika Mocko, Michael E. Fassbender

18th International Workshop on Targetry and Target Chemistry August 21<sup>st</sup> – August 26<sup>th</sup>, 2022 Whistler, BC

LA-UR-22-28249



### **Current Process – Isotope Production Facility**





#### **Current Process – Chemistry**

- Target dissolution
- GeCl<sub>4</sub> distillations
- AsCl<sub>3</sub> distillations
- Conversion to As(V)



Dissolution of the Ge target in 2:1 HCl:HNO<sub>3</sub> con. Mixture
 A white precipitate forms (bulk Ge as GeO<sub>2</sub>)



#### **Current Process – Possible Improvements**

- Target dissolution
- **GeCl**<sub>4</sub> distillations
- AsCl<sub>3</sub> distillations
- Conversion to As(V)

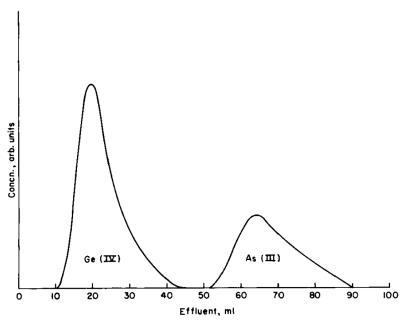




Series of long and delicate distillations required Critical As volatilization could lead to loss of final product



# Selected Literature: Anion-Exchange Separation in Hydrochloric Acid-Acetic Acid Medium



**FIG. 1.** Separation of 14 mg of germanium from 3.2 mg of arsenic(III) on a 10-g column of Dowex 1-X8 using 90 vol. % acetic acid-10 vol. % 9 N hydrochloric acid mixture and a flow rate of 1 ml/4.5 min.

Highly selective method allows for separation of Ge (IV), As(III) and As(V)

Best conditions found to be 90% A. Acid – 10% 9N HCl



## Selected Literature: Anion-Exchange Separation in Hydrochloric Acid Medium

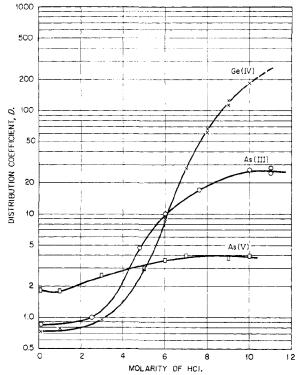


Fig. 1.—Adsorption of Ge(IV), As(III) and As(V).

Strong adsorption of both Ge(IV) and As(III) at high HCl concentration

As(III) adsorption levels off at 10M HCI while Ge(IV) still increases

Separation of As(V) from Ge(IV) readily achievable at high HCl concentration (As(V) and Ge(IV) would require larger volumes)



### Recovery of <sup>73</sup>As and <sup>74</sup>As

#### Normal process:

<sup>73</sup>As (80.30 days, 53 KeV) Co-produced <sup>74</sup>As (17.77 days, 595 KeV) is used as tracer during separation

<sup>68</sup>Ge (270.93 days) Its daughter <sup>68</sup>Ga (67.71 min, 1077 Kev) also used as tracer

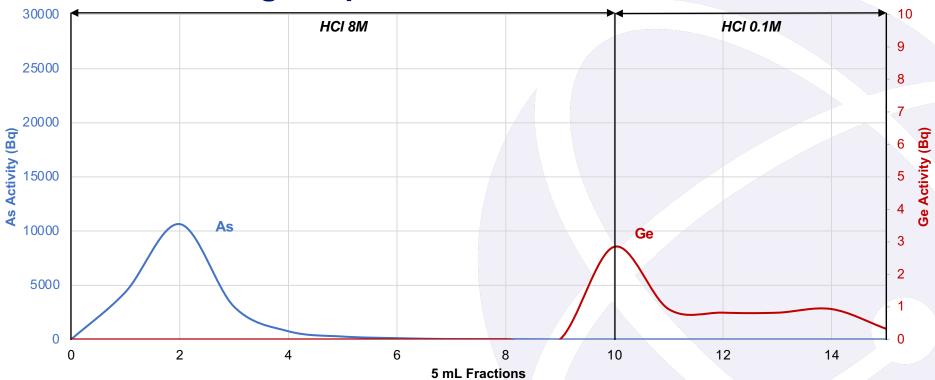
#### **R&D** Improvement:

Older material (dissolved target solutions) available

Lower activity, and difficult tracking

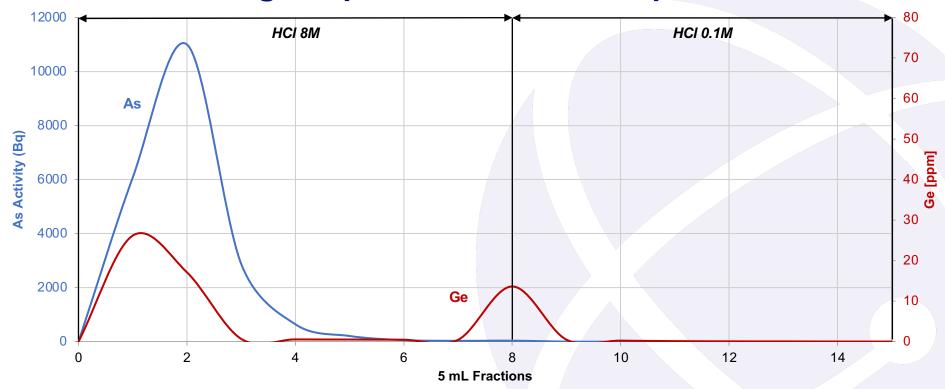


#### **Anion-Exchange Separation – 8M HCI**



Elution profile of the separation of As and Ge in HCl media followed by  $\gamma$ -ray spectrometry. 5mL HCl spiked with 100 µL radiotracers solution, and loaded onto 1.2822 g of AG1-X8 resin. (-) <sup>68</sup>Ge activity at 511 Key, (-) <sup>73</sup>As activity at 53 Key.

#### Anion-Exchange Separation – 8M HCI, Spiked Ge ICP Std

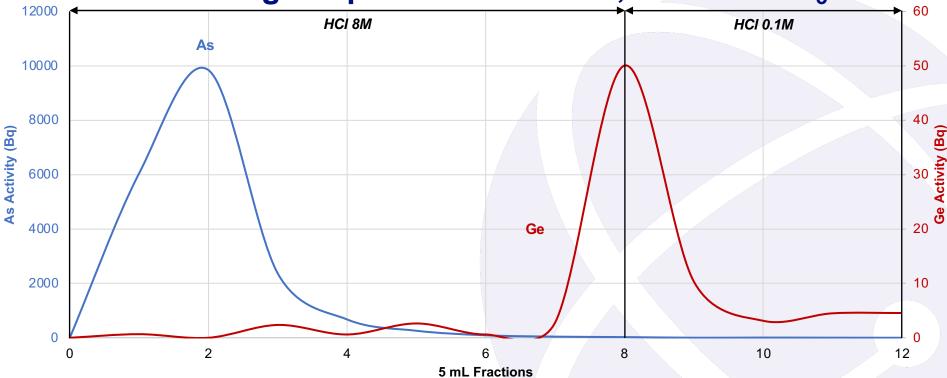


Elution profile of the separation of As and Ge in HCl media followed by γ–ray spectrometry and ICP-OES.

4mL HCl spiked with 750 μL radiotracers solution, 500 μL Ge ICP std, and loaded onto 1.3547 g of AG1-X8 resin.

(-) Ge at 209.426 nm, (-) <sup>73</sup>As activity at 53 Kev.

## Anion-Exchange Separation – 8M HCI, Traces HNO<sub>3</sub>

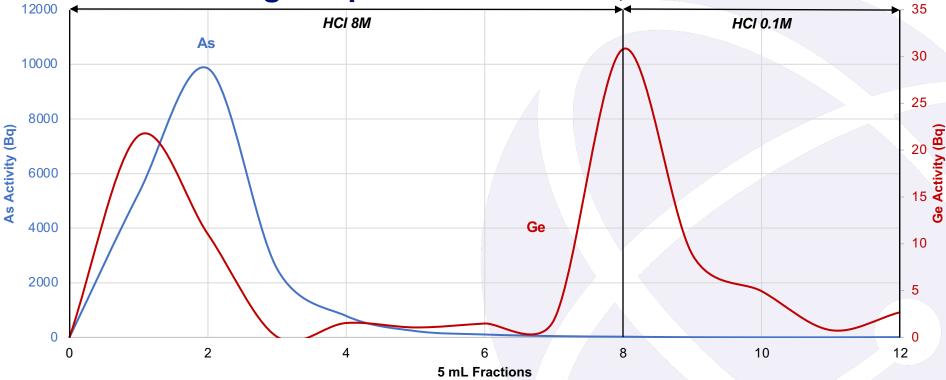


Elution profile of the separation of As and Ge in HCl media followed by γ–ray spectrometry.

4mL HCl spiked with 750 μL radiotracers solution, 33 μL HNO<sub>3</sub> con, and loaded onto 1.3383 g of AG1-X8 resin.

(-) <sup>68</sup>Ge activity at 511 Kev, (-) <sup>73</sup>As activity at 53 Kev.

#### **Anion-Exchange Separation – 8M HCI, Traces HF**

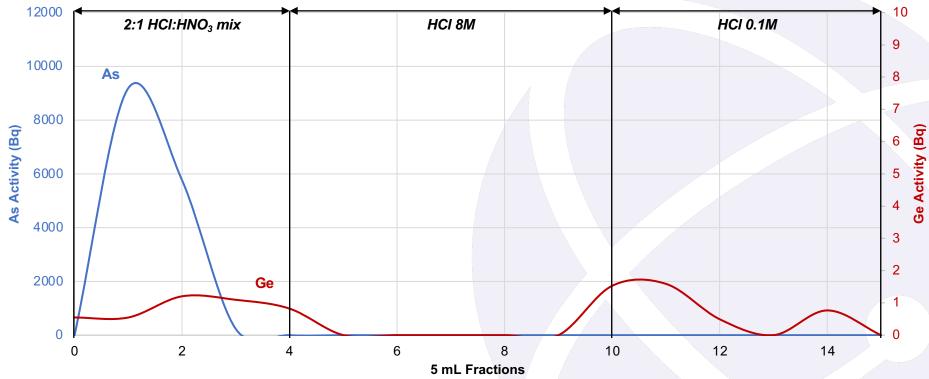


Elution profile of the separation of As and Ge in HCl media followed by γ–ray spectrometry.

4mL HCl spiked with 750 μL radiotracers solution, 20 μL HF con, and loaded onto 1.3526 g of AG1-X8 resin.

(-) <sup>68</sup>Ge activity at 511 Kev, (-) <sup>73</sup>As activity at 53 Kev.

#### Anion-Exchange Separation – 2:1 HCI:HNO<sub>3</sub> con



Elution profile of the separation of As and Ge in HCl media followed by γ–ray spectrometry.

5 mL of 2:1 HCl:HNO<sub>3</sub> mixture spiked with 100 μL radiotracers solution, and loaded onto 1.3211 g of AG1-X8 resin.

(-) <sup>68</sup>Ge activity at 511 Kev, (-) <sup>73</sup>As activity at 53 Kev.

#### **Anion-Exchange Separation – Hot Cell test**



Elution profile of the separation of As and Ge in HCl 8M followed by γ–ray spectrometry and ICP-OES. 31.3910 g of dissolved target load solution (30 mL) loaded onto 21.2188 g (30 mL) of AG1-X8 resin.

(-) Ge at 209.426 nm, (-) <sup>73</sup>As activity at 53 Kev.

#### **Conclusions and Future Work**

- Confirmed feasibility of As/Ge separation via anion exchange resin
- Fast, quantitative separation can be easily implemented in process
- Streamlined process

Implementation on even larger scale for next batch (Oct 2022)



#### **Acknowledgments**

LANL Isotope Team

Michael Fassbender Veronika Mocko

Artem Matyskin Jan Klouda Ivis Chaple

This research is supported by the U.S. Department of Energy Isotope Program, managed by the Office of Science for Isotope R&D and Production





